

Short Communication

Synthesis of Carboxylic Acid Derivatives of Dihydrochalcones

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Summary. Reaction of chalcones **1–8** with thioglycolic acid, 3-mercaptopropionic acid or thiosalicylic acid gives dihydrochalcone derivatives **9–23**.

Keywords. Chalcones; Dihydrochalcones; Nucleophilic addition.

Darstellung von Carbonsäurederivaten von Dihydrochalconen (Kurze Mitt.)

Zusammenfassung. Umsetzung der Chalcone **1–8** mit Thioglycolsäure, 3-Mercaptopropionsäure oder Thiosalicylsäure liefert die Dihydrochalconeabkömmlinge **9** bis **23**.

Reaction of chalcones and their heterocyclic analogues with thiols has been investigated by several research groups [1–8]. Substances prepared in this way were found to possess fungicide [4], antiinflammatory [8], and various other activities.

In the course of our studies on the synthesis of pharmacologically active chalcone derivatives the reaction of chalcones **1–8** with thioglycolic acid, 3-mercaptopropionic acid or thiosalicylic acid in hot toluene has been studied; thereby carboxylic acid derivatives of dihydrochalcones **9–23** were obtained (compare formula scheme and Table 1). The structure of these compounds has been elucidated by ¹H-NMR spectroscopy by assigning the CH₂ and CH aliphatic signals characteristic for the dihydrochalcone skeleton. ¹H-NMR spectral data are summarized in Table 1. All compounds showed antifungal activity: **9**, **13**, and **22** were especially active against *Aspergillus niger*, *Trichophyton mentagrophytes*, *Micosporum gypseum*, and *Epidermophyton floccosum* strains.

Experimental Part

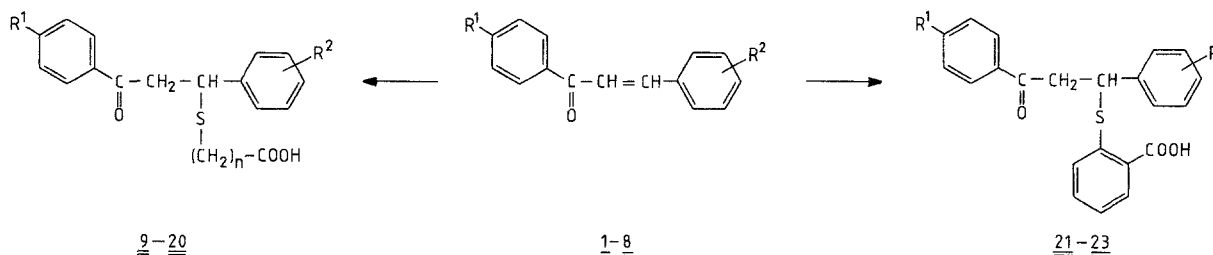
The NMR spectra were recorded on a Bruker WP 200 SY spectrometer in CDCl₃ (internal standard TMS, δ=0.0 ppm) at room temperature. TLC was performed on Kieselvel 60 F₂₅₄ (Merck) layer using hexane:acetone (7:3 v/v) as eluant. Starting materials **1–8** were prepared according to known methods [9–12].

Table 1. Physical constants and ^1H -NMR spectral data of compounds **9–23**

Com- pound	M.p. °C	Yield %	Molecular formula ^a	^1H -NMR δ (ppm)
9	137–138 ^b	75.0	$\text{C}_{17}\text{H}_{16}\text{O}_3\text{S}$	3.10 (dd, 2 H), 3.60 (d, 2 H), 4.80 (t, 1 H), 7.28–7.96 (m, 10 aromatic protons), 11.15 (s, 1 H)
10	105–106	73.9	$\text{C}_{17}\text{H}_{15}\text{ClO}_3\text{S}$	3.25 (dd, 2 H), 3.68 (d, 2 H), 5.26 (t, 1 H), 7.16–9.97 (m, 9 aromatic protons), 10.03 (s, 1 H)
11	145–146	89.8	$\text{C}_{17}\text{H}_{15}\text{ClO}_3\text{S}$	3.08 (dd, 2 H), 3.57 (d, 2 H), 4.75 (t, 1 H), 7.27–7.92 (m, 9 aromatic protons)
12	121–122	75.7	$\text{C}_{17}\text{H}_{14}\text{Cl}_2\text{O}_3\text{S}$	3.10 (dd, 2 H), 3.60 (d, 2 H), 4.70 (t, 1 H), 7.26–8.90 (m, 8 aromatic protons)
13	147–148	79.5	$\text{C}_{17}\text{H}_{14}\text{Cl}_2\text{O}_3\text{S}$	3.60 (d, 2 H), 3.90 (dd, 1 H), 4.30 (dd, 1 H), 5.72 (t, 1 H), 7.20–8.30 (m, 8 aromatic protons)
14	128–129	68.1	$\text{C}_{17}\text{H}_{15}\text{ClO}_3\text{S}$	3.08 (dd, 2 H), 3.58 (d, 2 H), 4.78 (t, 1 H), 7.25–7.87 (m, 9 aromatic protons), 10.86 (s, 1 H)
15	134–135	78.7	$\text{C}_{17}\text{H}_{15}\text{BrO}_3\text{S}$	3.08 (dd, 2 H), 3.56 (d, 2 H), 4.77 (t, 1 H), 7.25–7.80 (m, 9 aromatic protons), 9.72 (s, 1 H)
16	161–162	77.3	$\text{C}_{18}\text{H}_{18}\text{O}_3\text{S}$	2.55 (dd, 4 H), 3.52 (d, 2 H), 4.58 (t, 1 H), 7.28–7.93 (m, 10 aromatic protons)
17	113–114	60.5	$\text{C}_{18}\text{H}_{17}\text{ClO}_3\text{S}$	2.65 (dd, 4 H), 3.54 (d, 2 H), 5.15 (t, 1 H), 7.12–7.95 (m, 9 aromatic protons), 10.94 (s, 1 H)
18	131–132	83.0	$\text{C}_{18}\text{H}_{17}\text{ClO}_3\text{S}$	2.58 (dd, 4 H), 3.52 (d, 2 H), 4.57 (t, 1 H), 7.26–7.94 (m, 9 aromatic protons), 10.57 (s, 1 H)
19	102–103	67.9	$\text{C}_{18}\text{H}_{16}\text{Cl}_2\text{O}_3\text{S}$	2.64 (dd, 4 H), 3.56 (dd, 2 H), 5.08 (t, 1 H), 7.14–7.92 (m, 8 aromatic protons)
20	132–133	58.4	$\text{C}_{18}\text{H}_{16}\text{Cl}_2\text{O}_3\text{S}$	1.48 (dd, 2 H), 1.66 (dd, 2 H), 2.50 (dd, 1 H), 2.77 (dd, 1 H), 4.26 (t, 1 H), 5.82–6.70 (m, 8 aromatic protons)
21	166–167	68.4	$\text{C}_{22}\text{H}_{18}\text{O}_3\text{S}$	3.70 (dd, 2 H), 5.18 (dd, 1 H), 7.20–8.10 (m, 14 aromatic protons)
22	139–140	61.0	$\text{C}_{22}\text{H}_{17}\text{ClO}_3\text{S}$	3.64 (dd, 2 H), 5.80 (dd, 1 H), 7.10–8.10 (m, 13 aromatic protons)
23	159–160	65.5	$\text{C}_{22}\text{H}_{17}\text{ClO}_3\text{S}$	3.62 (dd, 2 H), 5.18 (dd, 1 H), 7.20–8.12 (m, 13 aromatic protons)

^a Elemental analyses (C, H, S) were in good agreement with the calculated values^b Ref. [2] m.p. 126 °C*General Procedure for the Preparation of Compounds 9–23*

A mixture of compounds **1–8** (20.0 mmol), mercaptocarboxylic acid (30.0 mmol), and toluene (100.0 ml) was refluxed for 6 h, the solvent evaporated in vacuum and the residue crystallized from benzene to afford substances **9–23**. For properties see Table 1.



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| <p>1: $R^1 = R^2 = \text{H}$</p> <p>2: $R^1 = \text{H}, R^2 = 2\text{-Cl}$</p> <p>3: $R^1 = \text{H}, R^2 = 4\text{-Cl}$</p> <p>4: $R^1 = \text{H}, R^2 = 2,4\text{-Cl}_2$</p> <p>5: $R^1 = \text{H}, R^2 = 3,4\text{-Cl}_2$</p> <p>6: $R^1 = \text{H}, R^2 = 2,6\text{-Cl}_2$</p> <p>7: $R^1 = \text{Cl}, R^2 = \text{H}$</p> <p>8: $R^1 = \text{Br}, R^2 = \text{H}$</p> <p>9: $R^1 = , R^2 = \text{H}$</p> <p>10: $R^1 = \text{H}, R^2 = 2\text{-Cl}, n = 1$</p> <p>11: $R^1 = \text{H}, R^2 = 4\text{-Cl}, n = 1$</p> <p>12: $R^1 = \text{H}, R^2 = 3,4\text{-Cl}_2, n = 1$</p> | <p>13: $R^1 = \text{H}, R^2 = 2,6\text{-Cl}_2, n = 1$</p> <p>14: $R^1 = \text{Cl}, R^2 = \text{H}, n = 1$</p> <p>15: $R^1 = \text{Br}, R^2 = \text{H}, n = 1$</p> <p>16: $R^1 = R^2 = \text{H}, n = 2$</p> <p>17: $R^1 = \text{H}, R^2 = 2\text{-Cl}, n = 2$</p> <p>18: $R^1 = \text{H}, R^2 = 4\text{-Cl}, n = 2$</p> <p>19: $R^1 = \text{H}, R^2 = 2,4\text{-Cl}_2, n = 2$</p> <p>20: $R^1 = \text{H}, R^2 = 2,6\text{-Cl}_2, n = 2$</p> <p>21: $R^1 = R^2 = \text{H}$</p> <p>22: $R^1 = \text{H}, R^2 = 2\text{-Cl}$</p> <p>23: $R^1 = \text{Cl}, R^2 = \text{H}$</p> |
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Acknowledgements

The present study was sponsored by the Biogal Pharmaceutical Works (Debrecen, Hungary) for which our gratitude is expressed. Our thanks are due to Mrs. E. Hajnal and Mrs. M. Nagy for their help in the experimental work.

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Received June 25, 1990. Accepted July 4, 1990

Verleger: Springer-Verlag KG, Mölkerbastei 5, A-1010 Wien. — Herausgeber: Österreichische Akademie der Wissenschaften, Dr.-Ignaz-Seipel-Platz 2, A-1010 Wien, und Gesellschaft Österreichischer Chemiker, Eschenbachgasse 9, A-1010 Wien. — Redaktion: Währinger Straße 38, A-1090 Wien. — Hersteller: Adolf Holzhausens Nachfolger, Kandlgasse 19-21, A-1070 Wien. — Verlagsort: Wien. — Herstellungsort: Wien. — Printed in Austria.

Offenlegung gem. § 25 Abs. 1 bis 3 Mediengesetz: Unternehmensgegenstand: Verlag von wissenschaftlichen Büchern und Zeitschriften. An der Springer-Verlag GmbH & Co. KG ist beteiligt: Dr. Konrad F. Springer, Mölkerbastei 5, A-1010 Wien, als Kommanditist zu 52,38%. Geschäftsführer: Dr. Konrad F. Springer, Prof. Dr. Dietrich Götze, Ing. Wolfram F. Joos, Dipl.-Kfm. Claus Michaelitz und Rudolf Siegle, alle Mölkerbastei 5, A-1010 Wien.